

Fast Tunable Blazed MEMS Gratings and the Use of X-Ray Diffraction for Early Failure Detection

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A. Hoogerwerf*

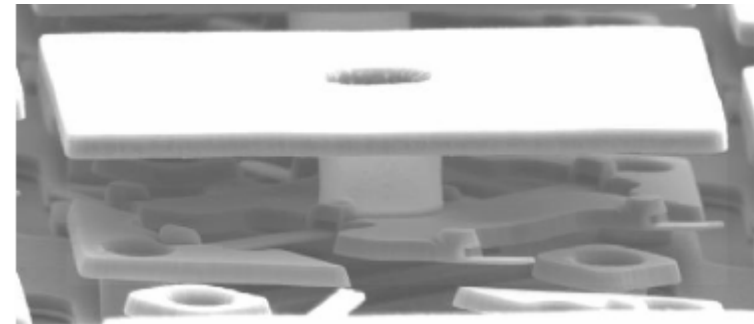
6th ESA Round Table, 8-12 October 2007

Optical MEMS to deflect light

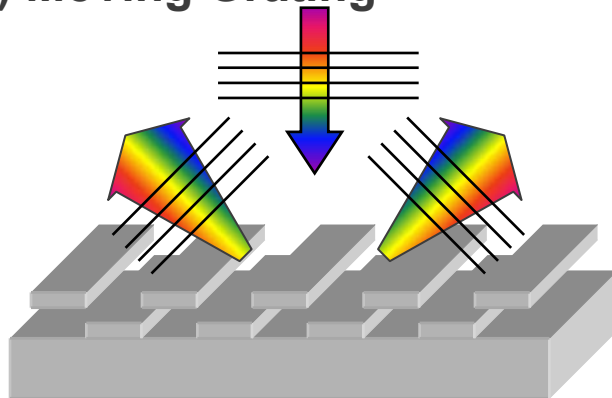
(1) Moving Mirror (Lucent Technology)



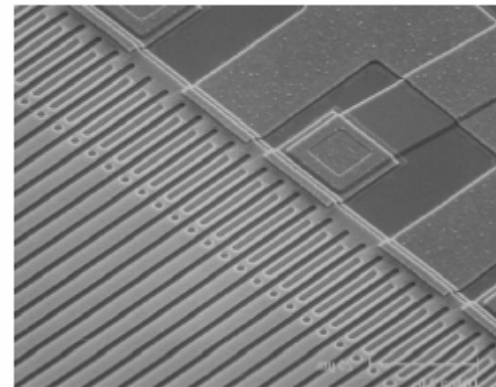
DLP™ (Texas Instruments)



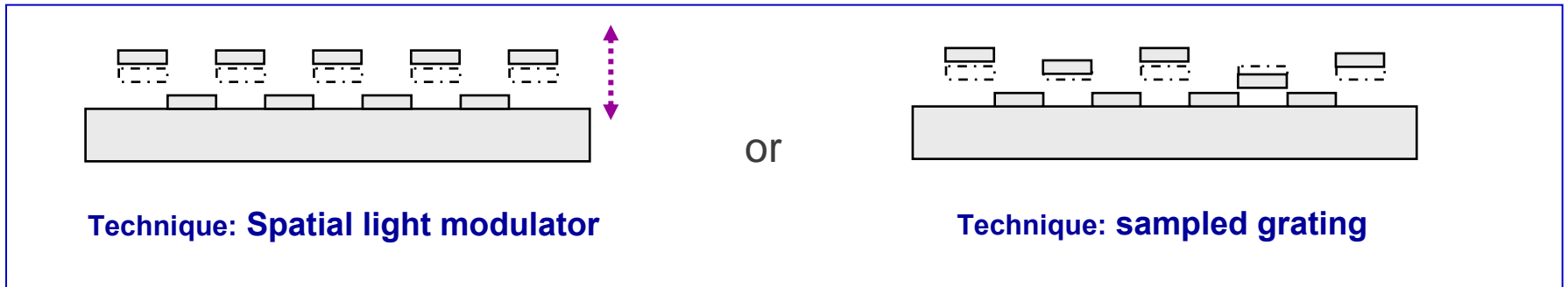
(2) Moving Grating



GLV™ (Silicon Light Machines)

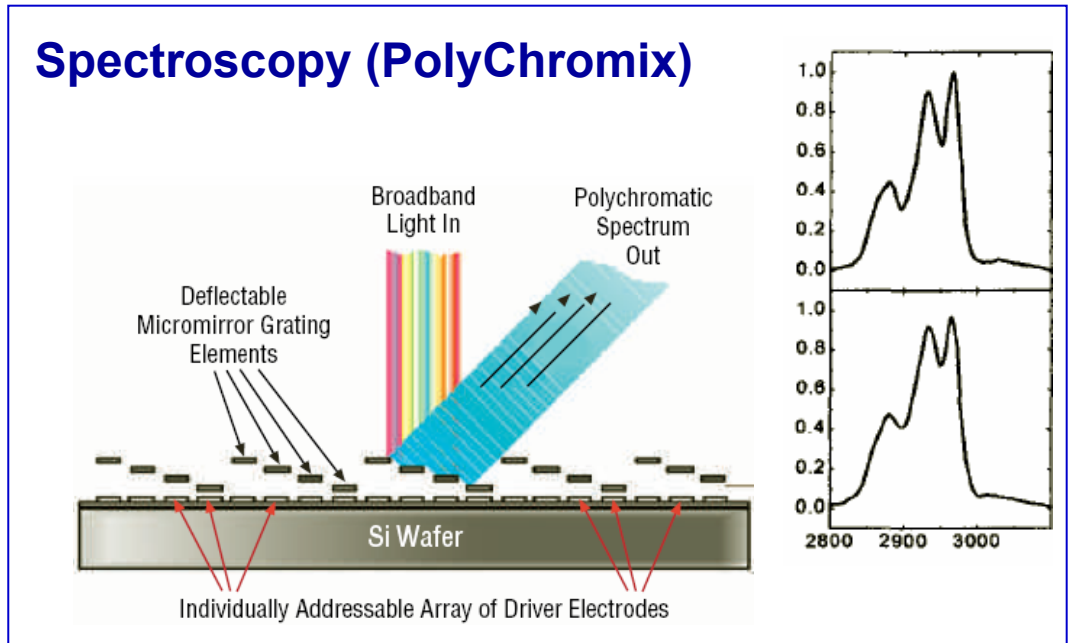


Two families of PDMG's: 1st Family – Piano Gratings

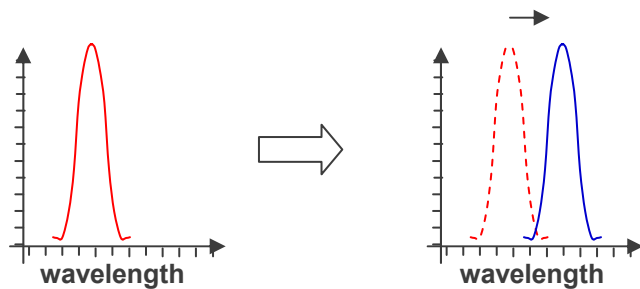
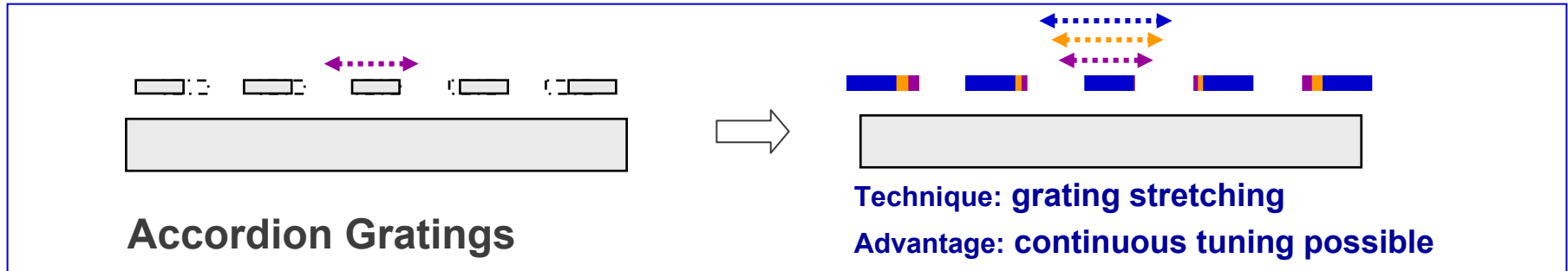


Piano Gratings can be used as

- (A) **switchable pixels**
- (B) **to make synthetic spectra**



2nd family of PDMG's – Accordion Gratings

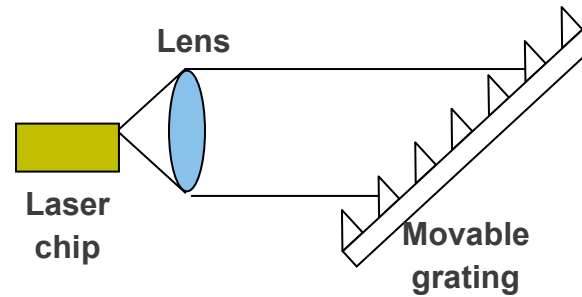


Applications:

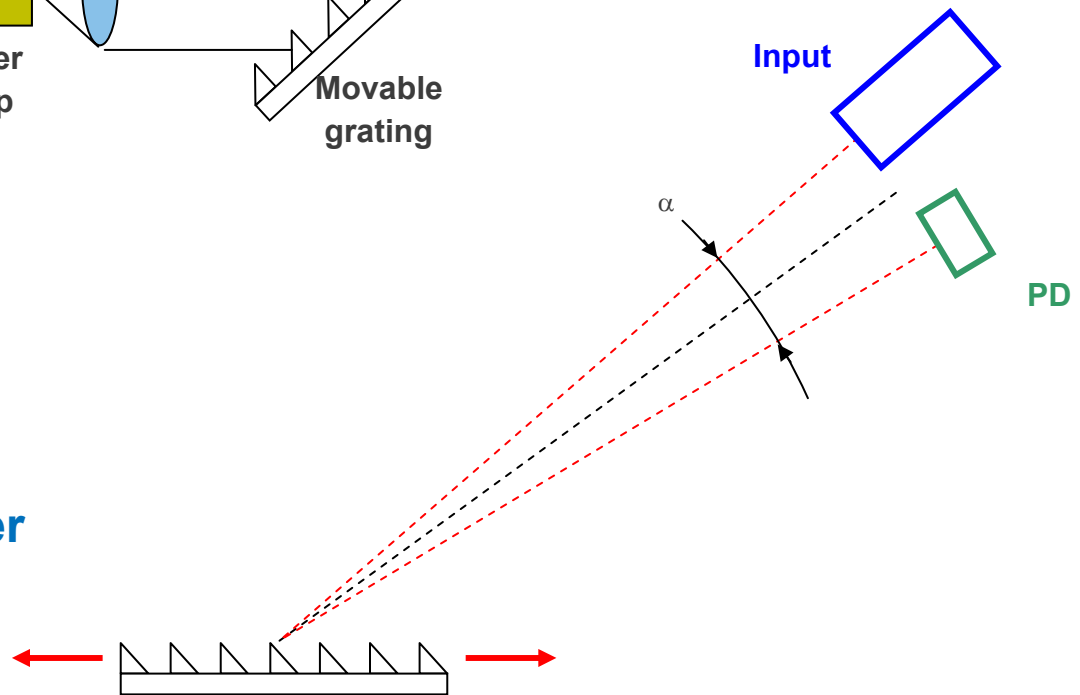
- Tunable filters
- External Cavity Lasers
- Spectrometers

Basic applications concepts

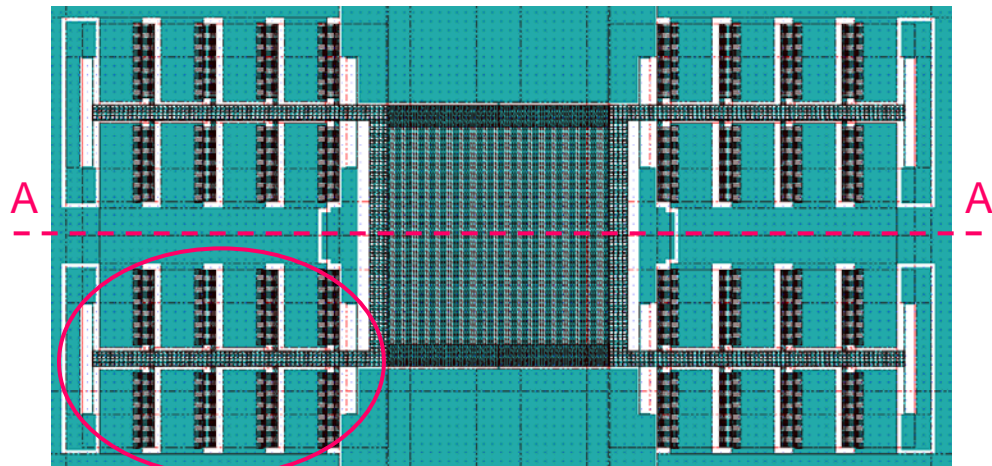
Tunable laser



Grating Spectrometer



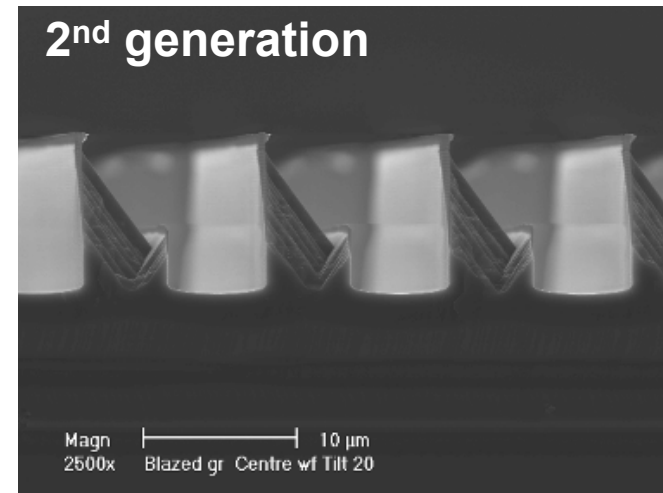
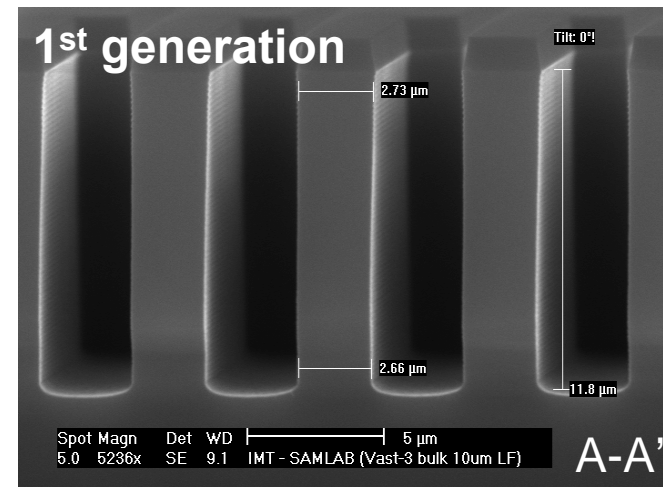
Blazed movable gratings



Comb drives

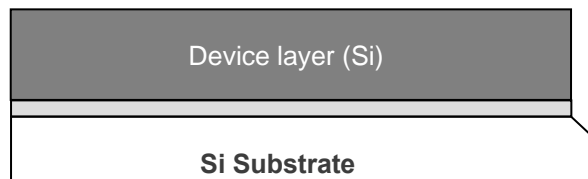
Grating properties

- 1mm x 1mm
- Period 12 μm
- *Blazed* (54.74°, Littrow condition)
- Maximum tuning: 6%
- For $\lambda = 700 \text{ nm} \Leftrightarrow$ 28th diffraction order!

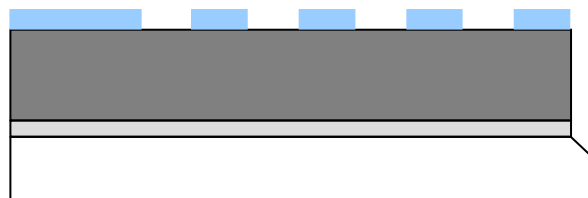


Process Flow

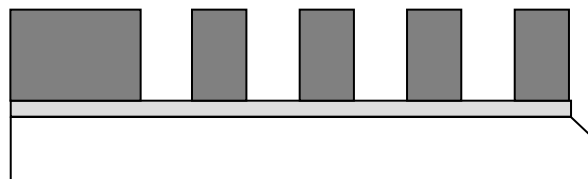
(1) Low-resistivity SOI wafer.



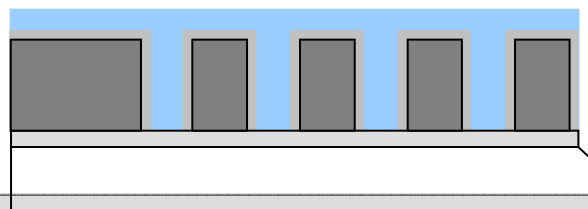
(2) Patterning of structures.



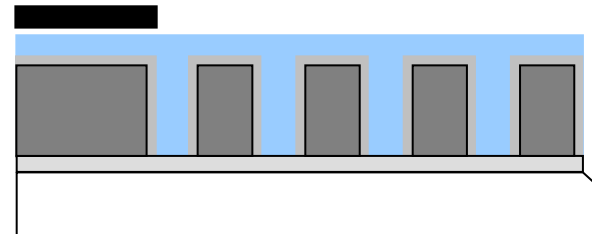
(3) Dry etching / Resist removal



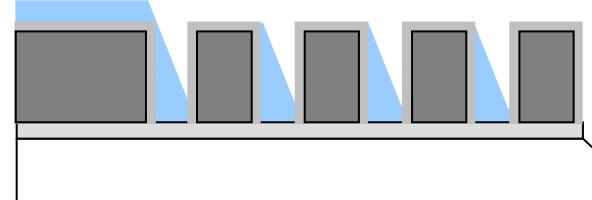
(4) Thermal Oxidation / Resist spinning



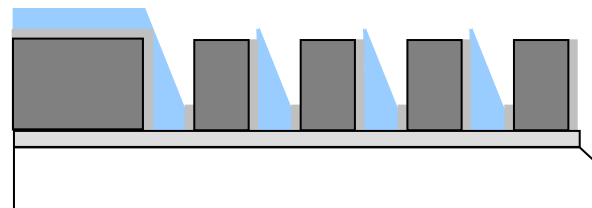
(5) Exposure at 30°



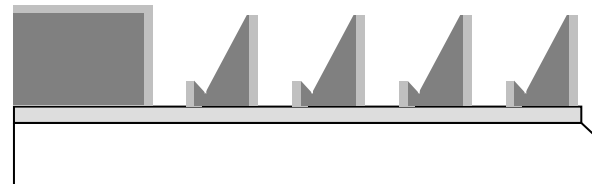
(6) Resist development



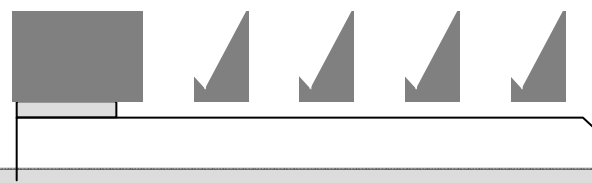
(7) BHF etch



(8) Anisotropic KOH etch / Resist Stripping

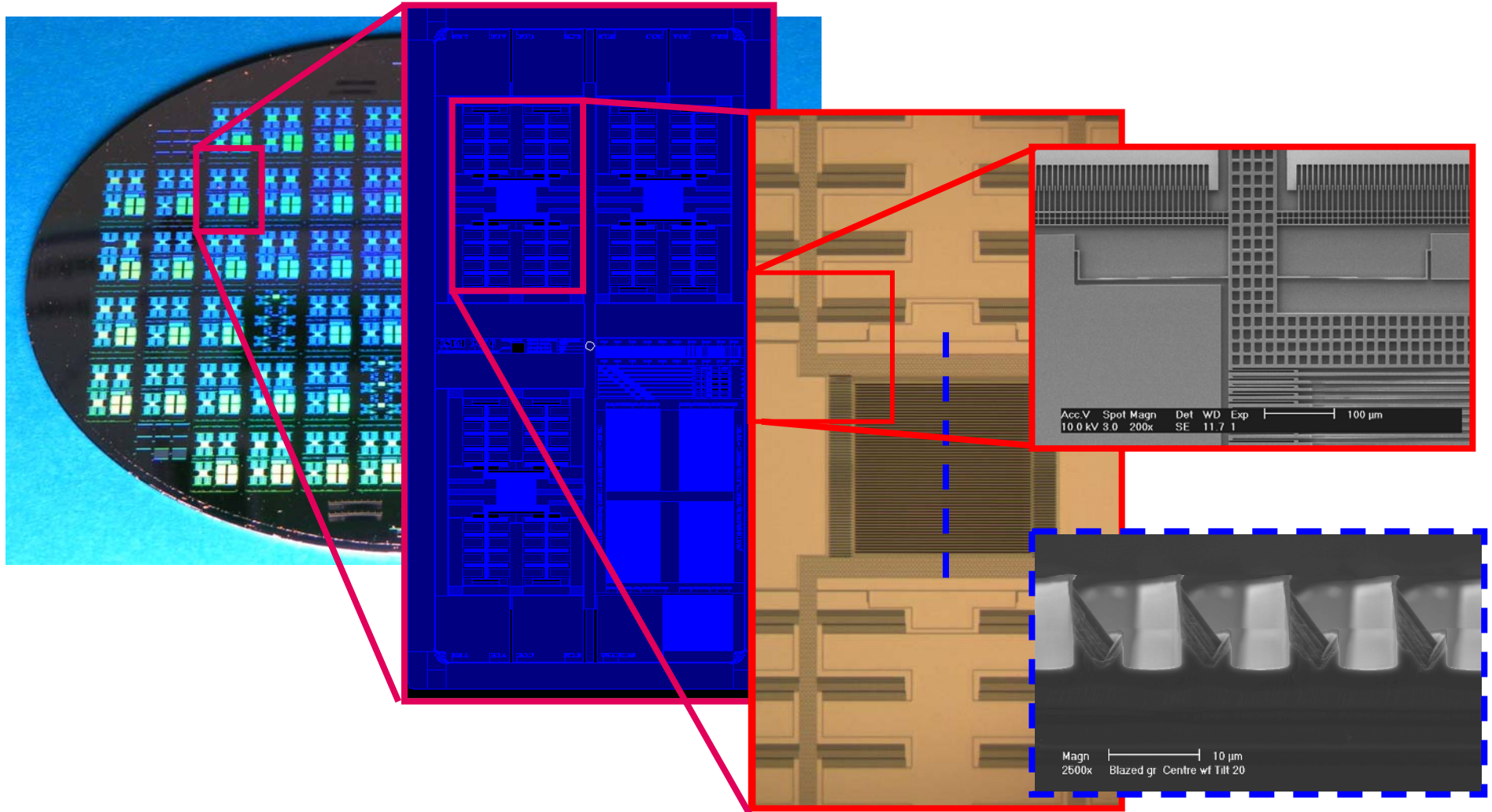


(9) HF vapour release



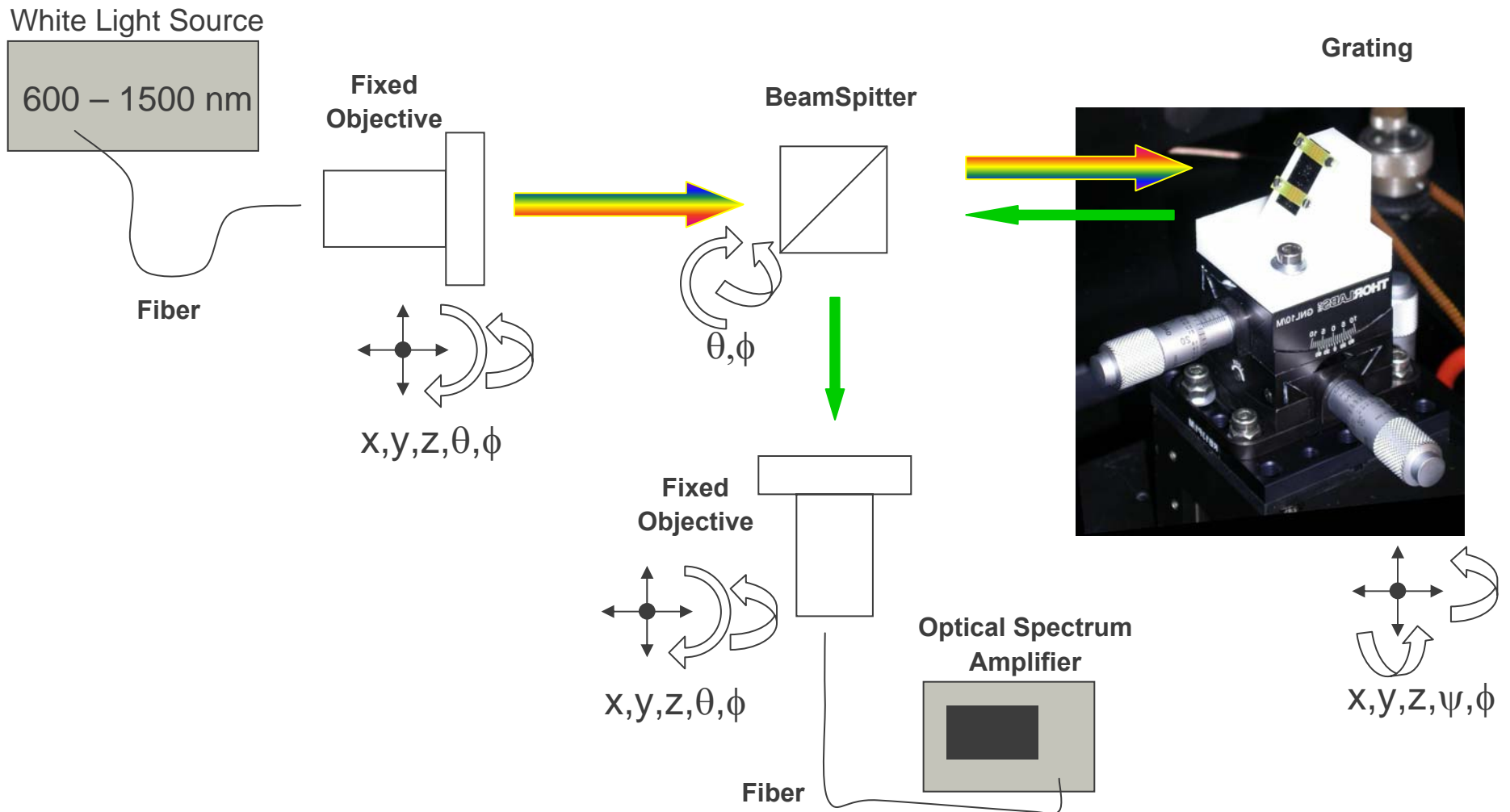
Fabrication

Blazed movable gratings

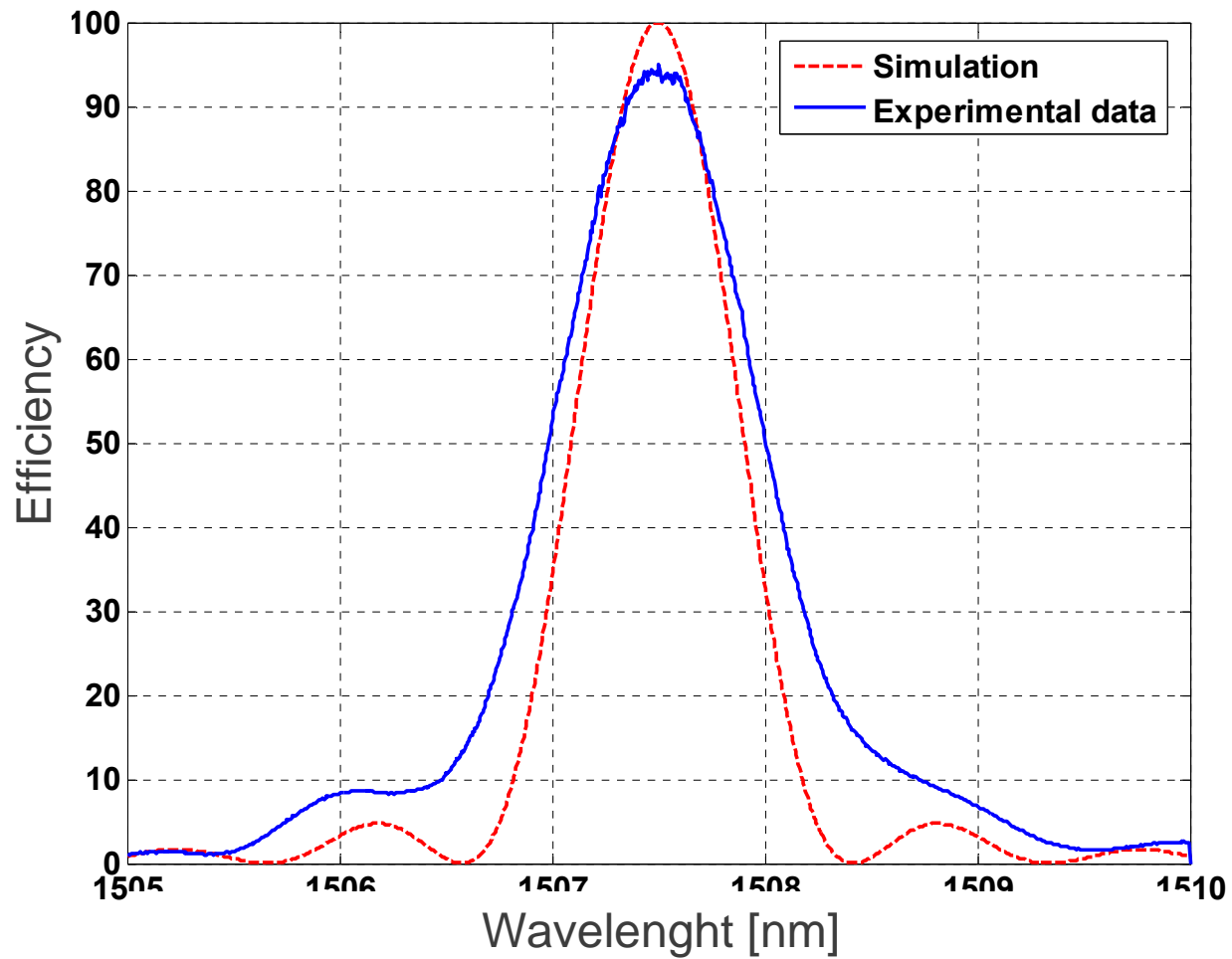


Characterization

Optical Characterization setup

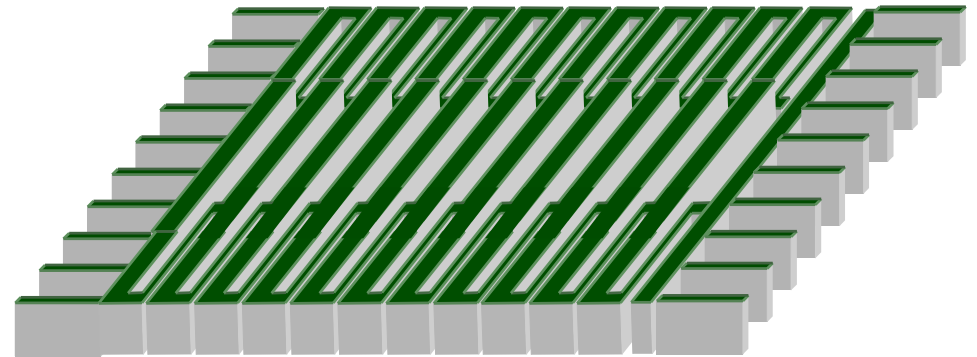


Optical performances

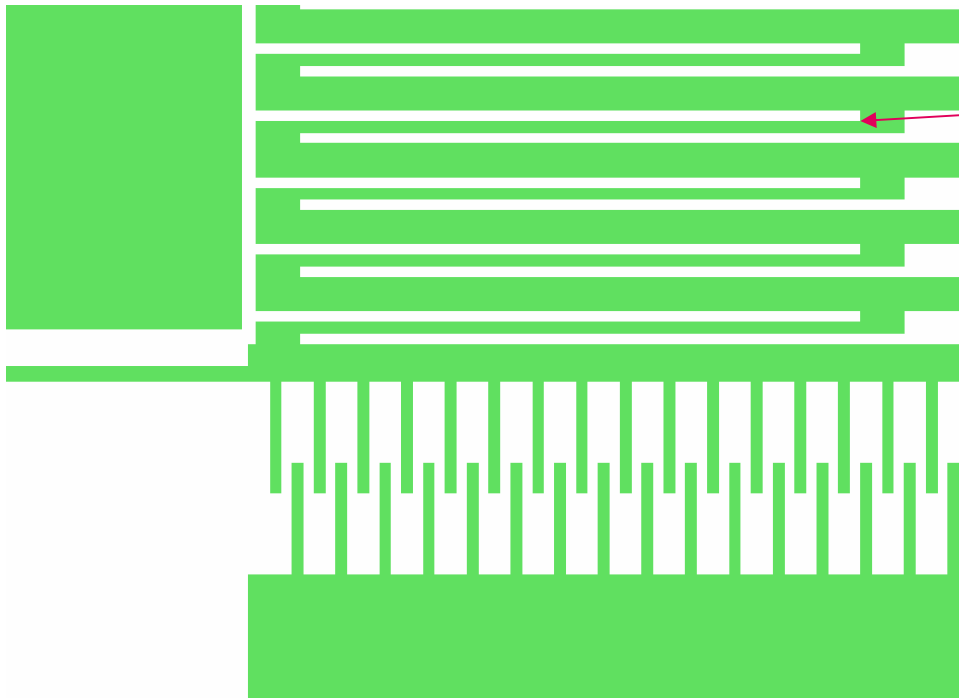


Design Challenges

1. Free standing grating
 - rigid enough to be held
 - but flexible enough to be actuated
2. Springs need to be identical
3. Diffracting beams - distortion free
 - in-plane bending
 - out-of-plane buckling
 - rotation
4. High quality optical surfaces



Spring & comb actuator design



- **Accordion springs**
 - leaf hinges
 - only flexible element
 - prevents beam rotation
 - prevents beam buckling
- **Maximum ideal displacement:**
 - 6 μm at each comb

Early Failure Detection

Lifetime of MEMS devices is correlated to aging, where aging is related to defects in the crystal lattice.

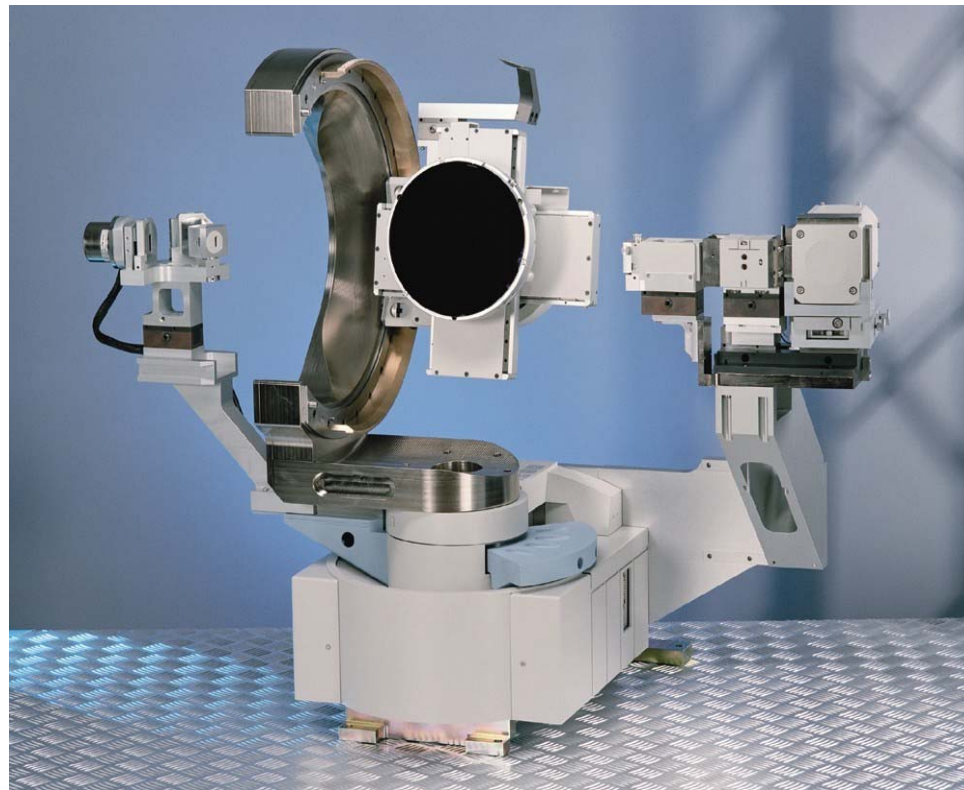
Defects induce stress

Stress can be determined from strain measurements (Hooke's law)

HRXRD Techniques:

- 1) Measurement of peak shape (rocking curve)**
- 2) Reciprocal Space Mapping (RSM)**
- 3) TDA (Triple crystal diffractometry)**

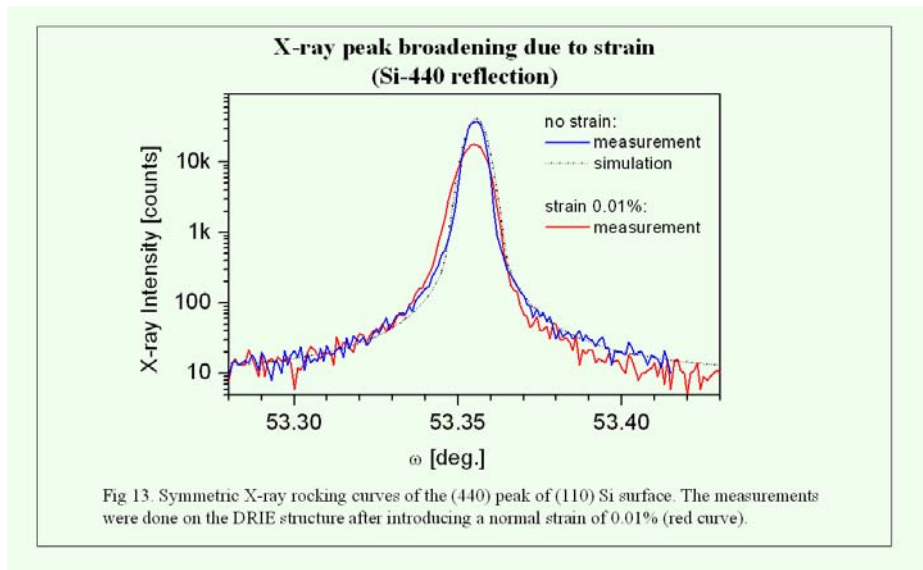
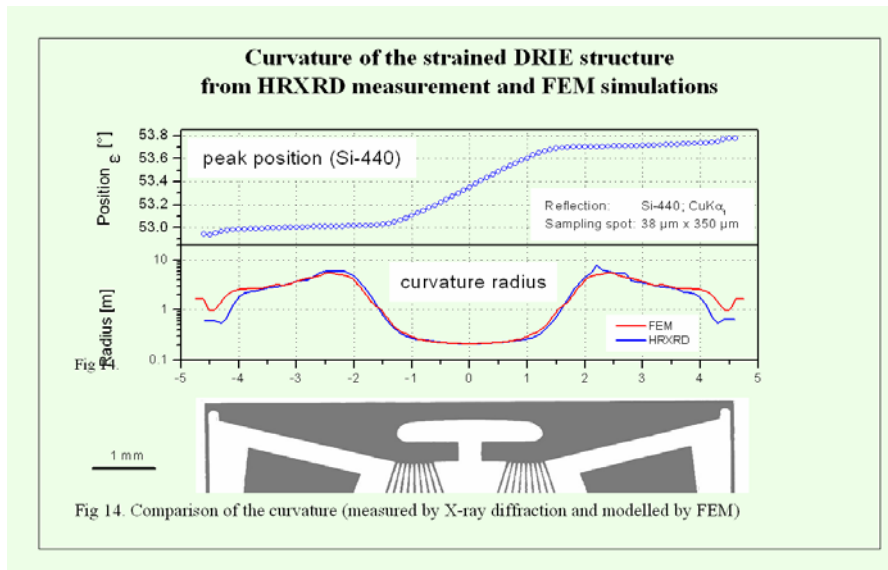
Study of Crystalline Imperfection in Si Microstructures and its correlation to mechanical properties and Aging



High Resolution X-Ray Techniques

HRXRD Techniques:

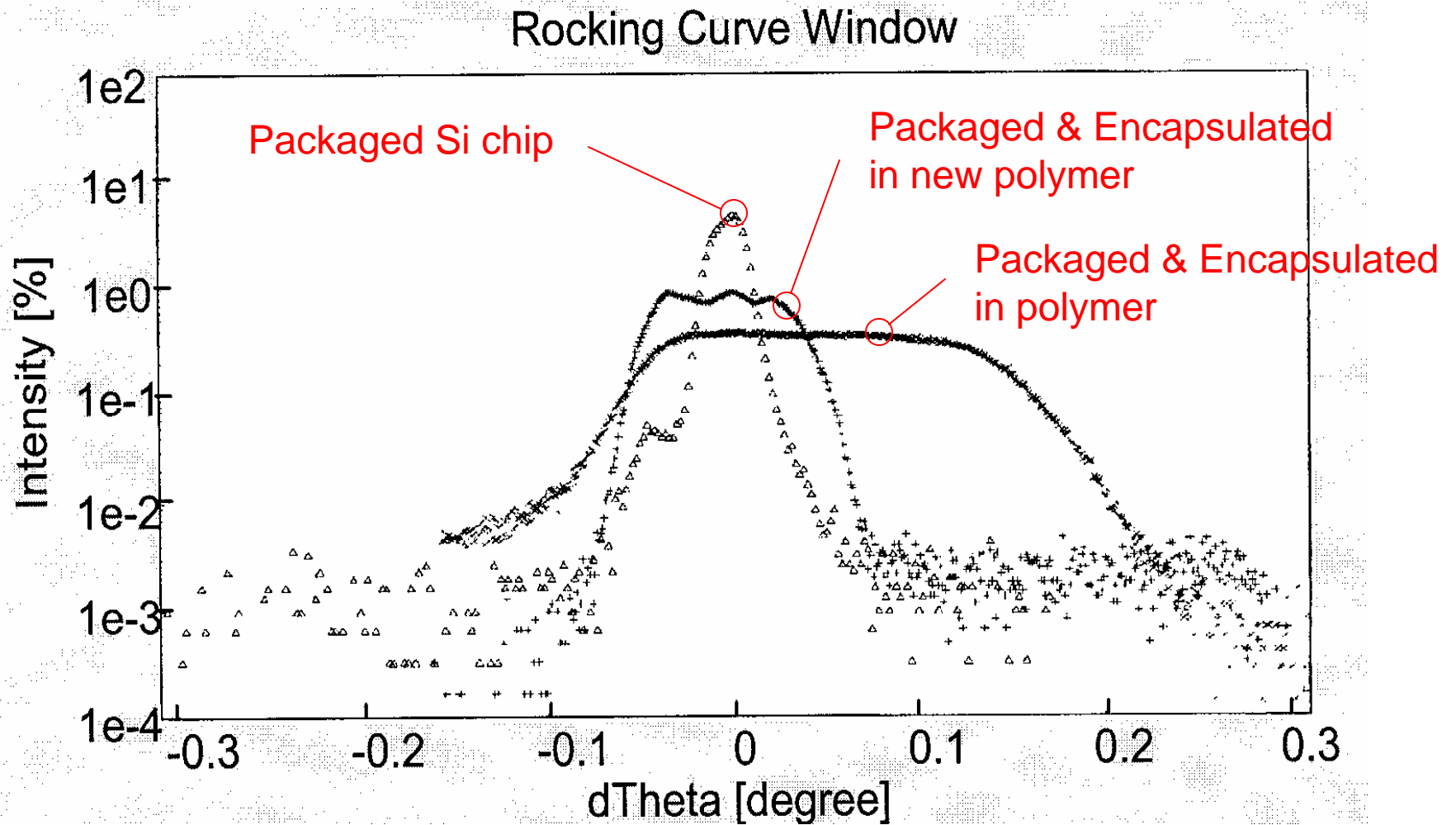
Strain measurement



- Traveling peak technique (curvature)

– Rocking curve (peak shape and width)
– Peak broadening due to a multitude of different lattice constants

Example: Encapsulation problem

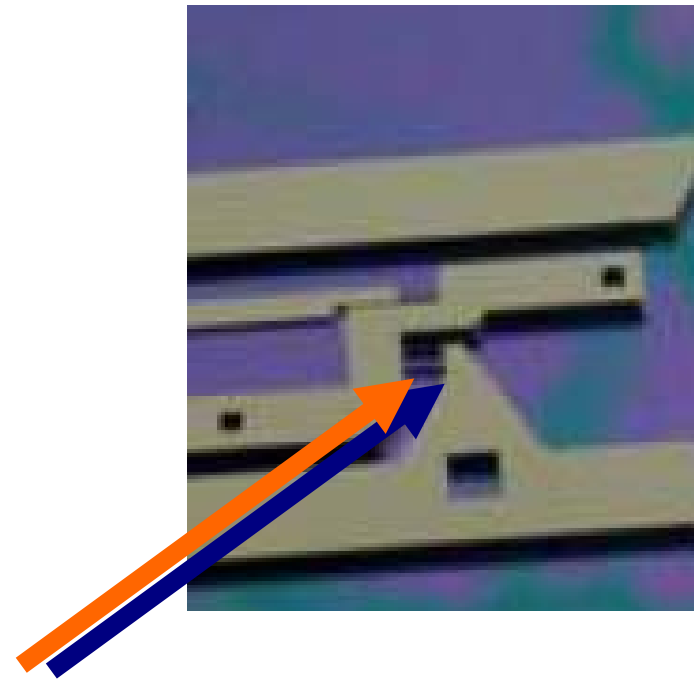
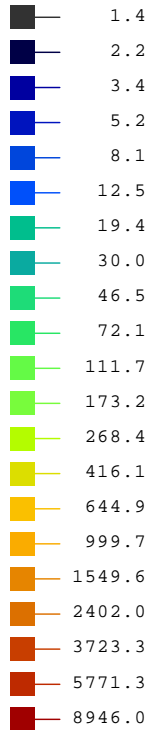
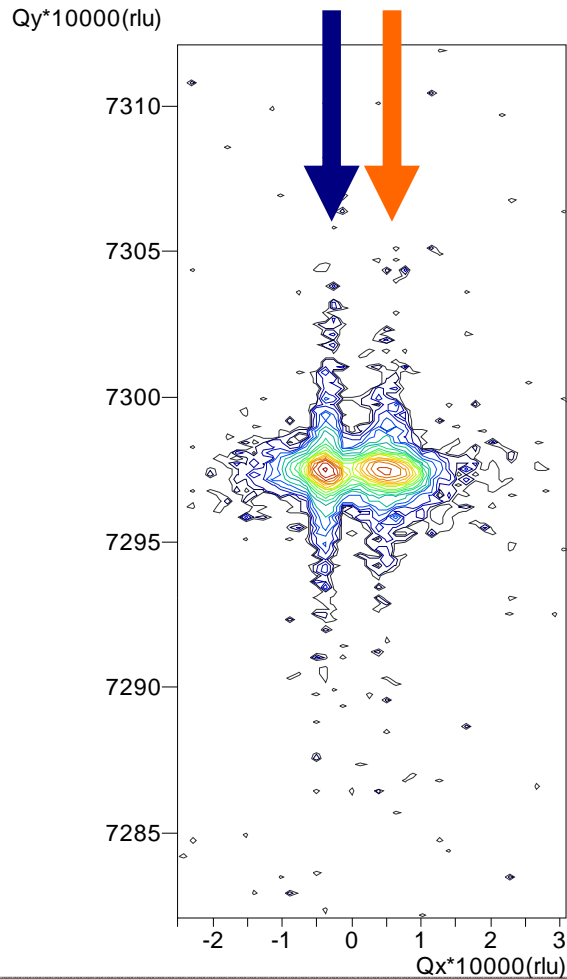


Si STRUCTURE

RSM on 004 (small and large parts exposed)

0 0 4 Omega 34.6000° Phi 0.00° X 0.00
 2Theta 69.2000° Psi 0.00° Y -2.00
 Z 0.000

Si-RSM-TA-004.xrdml



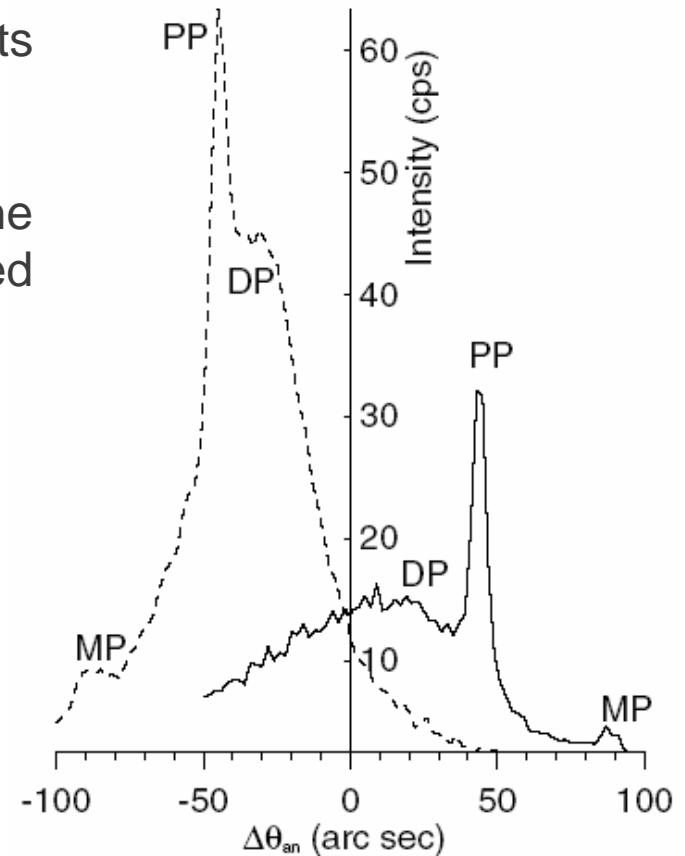
3) TCD (Tripple crystal diffractometry)

Study of diffused scattering due to the defects of the crystal lattice

Separation of the elastic component of the scattered intensity (Bragg) from the diffused one.

TCD spectra for $\theta = +45$ arc s (full curve) and $\theta = -45$ arc s (broken curve).

MP, main peak
PP, pseudo peak
DP, diffuse peak.



Conclusion

- Deformable MEMS accordion grating with electrostatic actuation
- High blaze angle → high order → high resolution with a “small” number of grooves
- Wide tuning range
- Applicable to VIS, near IR and mid IR
- Soft HRXRD to determin strain → stress → defects → aging → failure

Thanks to...



P. Niedermann



J.-P. Morel



A.-C. Pliska



A. Hoogerwerf



M. Tormen



T. Overstolz



R. Lockhart



C. Ketterer



R. Stanley



A. Dommann

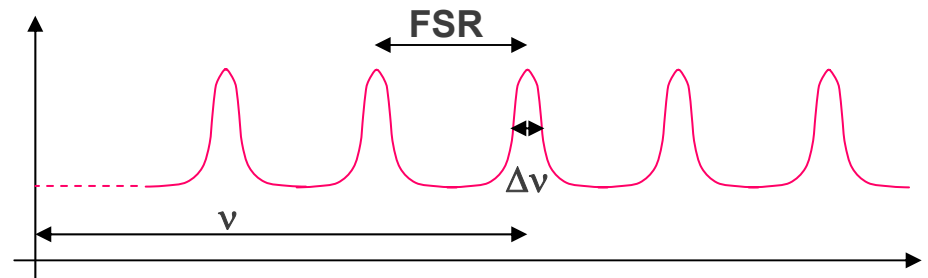
Fabrication was carried out at COMLAB, the joined facility between CSEM and IMT

Thank you for your attention.

$$\text{Resolving Power} \equiv Q \equiv \frac{\nu}{\Delta\nu}$$

$$\text{Finesse} \equiv \frac{\text{FSR}}{\Delta\nu}$$

where FSR is the Free Spectral Range



For a grating:

$$\text{Resolving Power} = m \cdot N$$

$$\text{Finesse} = N$$

where m is the diffraction order, N the number of grating teeth.

In order to have high Finesse and high $Q \rightarrow$ high m and high N are required

Color scheme

